
Adobe Photoshop 2021 (Version 22.1.1)

The invention relates to a mass spectrometer with an ion source, and more particularly to the operation of such an ion source to prevent the build-up of interfering species in the ion source which degrade the performance of the mass spectrometer. Mass spectrometers are devices for analyzing ions. Mass spectrometers use a variety of ionization techniques, including electron ionization (EI), chemical ionization (CI), and inductively coupled plasma ionization (ICP) to ionize analyte molecules within an ambient gas, which is then analyzed for selected characteristics. For example, mass spectrometers are commonly used to analyze the composition of a sample by examining the molecular weights of the sample components. A sample is introduced into the mass spectrometer, where it is ionized and the masses of the ions are analyzed to determine the compositions of the molecules. In an inductively coupled plasma mass spectrometer (ICP-MS), the plasma is formed in a plasma reactor of the mass spectrometer. The plasma reactor may be referred to as a torch or plasma torch to distinguish it from ionization sources of other types. The plasma reactor typically consists of a sampling orifice and a power supply. The sampling orifice permits the introduction of a sample stream, while the power supply provides the electrical power to sustain the plasma. In one example of an ICP-MS, the sample stream enters the plasma reactor through an orifice in a sampling cone. The orifice is typically provided at one end of a quartz torch, such as the Omniview™ torch sold by Elemental Chromatography Systems. The orifice has a multiplicity of orifice elements arranged to form a uniform sampling cone. While conventional sampling cones typically have a uniform cross-sectional area, the sampling cone may have other configurations, e.g., a tapered shape. One type of tapered sampling cone is described in U.S. Pat. No. 5,733,860. As the sample enters the sampling cone, the sampling cone directs the sample into the plasma reactor to form an inductively coupled plasma. The plasma is maintained by a power supply, which typically drives a coil about the plasma reactor. The use of multiple turns of coil results in an RF magnetic field that induces an RF voltage in the plasma reactor. The RF magnetic field is tuned such that the RF voltage results in a downward force on the ions within the plasma, so that they are trapped by a potential well. The frequency of the RF voltage and the number

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BSD-style // license that can be found in the LICENSE file. // +build linux package unix_test import (
"testing" "golang.org/x/sys/unix" ) func TestDevices(t *testing.T) { testCases := []struct { path string
major uint32 minor uint32 } { {"/dev/null", 0, 0}, {"/dev/zero", 0, 0}, {"/dev/tty0", 0, 0},
{"/dev/tty1", 0, 0}, } for _, tc := range testCases { t.Run(fmt.Sprintf("%s %v:%v", tc.path, tc.major,
tc.minor), func(t *testing.T) { var stat unix.Stat_t err := unix.Stat(tc.path, &stat) if err != nil {
t.Fatalf("failed to stat device: %v", err) t.FailNow() } dev := uint64(stat.Rdev) if unix.Major(dev) !=
tc.major { t.Fatalf("for %s Major(%#x) == %d, want %d", tc.path, dev, unix.Major(dev), tc.major) }
if unix.Minor(dev) != tc.minor { t.Fatalf("for %s Minor(%#x) == %d, want %d", tc.path, dev,
unix.Minor(dev), tc.minor) } if unix.Mkdev(tc.major, tc.minor) != dev { t.Fatalf("for %s Mkdev(%d,
%d) == %#x,
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System Requirements For Adobe Photoshop 2021 (Version 22.1.1):

Minimum: OS: Windows 7, Vista or XP Processor: 2.8 GHz Pentium IV or better Memory: 2 GB
RAM Graphics: Nvidia GeForce 9800 GT or ATI X1950 or better DirectX: DirectX 9.0c compatible
video card or DirectX 9.0c compatible video driver DirectX: DirectX 9.0c compatible video card or
DirectX 9.0c compatible video driver Additional: Windows XP with Service Pack 3 or DirectX 9.0c
installed Recommended: OS

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